

## **China BEAMeeting**



Time: Wednesday, April 02, 2025 9:30 – 12:00 (CST)

Location: 中国科学院半导体研究所 学术会议中心

Organizers: GenlSys GmbH, 中国科学院半导体研究所

BEAMeetings are a technical exchange platform for the direct write community focused on e-Beam and laser lithography, data-preparation, PEC, process correction, lithography simulation, and metrology. It is a platform for BEAMER users and those who are interested in GenISys software.

As in the past, it is a great opportunity to meet with the GenlSys team, have face to face in-depth discussions, exchange ideas and position your needs and wishes. On top of standard BEAMER/TRACER/LAB, this year we would like to emphasis ProSEM, our full metrology solution for the microscopy team of nano fabrication center.

We are looking forward to presenting you with an interesting and valuable workshop!

Thank you, The GenISys Team

## **Beijing BEAMeeting Agenda 2025**

Wednesday, April 02		
陈利奇/颜伟	开幕致辞	09:00
GenISys GmbH/半导体所		
任明华	BEAMER & TRACER 新版本更新	09:10
GenlSys GmbH		
陈利奇	LAB 电子束以及激光模拟仿真	09:40
GenlSys GmbH		
半导体用户	用户分享报告	10:10
中国科学院半导体研究所		
	休息时间	10:50
任明华	激光直写 3D PEC 灰度曝光修正	11:10
GenlSys GmbH		
陈利奇	ProSEM 以及 InSpec 测量软件介绍	11:40
GenISys GmbH		
	会议结束	12:00